


 Cite this: *RSC Adv.*, 2017, 7, 31969

DOI: 10.1039/c7ra90071f

www.rsc.org/advances

Correction: Stable DNA-based reaction–diffusion patterns

 John Zenk,^a Dominic Scalise,^a Kaiyuan Wang,^a Phillip Dorsey,^a Joshua Fern,^a Ariana Cruz^a and Rebecca Schulman^{*ab}

 Correction for 'Stable DNA-based reaction–diffusion patterns' by John Zenk *et al.*, *RSC Adv.*, 2017, 7, 18032–18040.

The authors regret that the acknowledgements incorrectly describe the funding provided by the DOE. The corrected acknowledgements are provided below.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

Acknowledgements

The authors would like to thank Deepak Agrawal, Angelo Cangialosi, Qi Huang, Abdul M. Mohammed, and Samuel Schaffter for helpful discussions, and Markela Ibo for her assistance with fabrication techniques for reaction–diffusion devices. This work was supported by DOE BES grant 90068952 for salary support of J. Z., P. D. and J. F., the materials and supplies used in experiments and analysis and modeling. Some early design work for this project was supported by NSF CCF grant 1161941.

^aChemical and Biomolecular Engineering, Johns Hopkins University, Baltimore, Maryland 21218, USA. E-mail: rschulm3@jhu.edu

^bComputer Science, Johns Hopkins University, Baltimore, Maryland 21218, USA

